

**PATENT**

**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

Serial No.: 10/675,419  
Art Unit: 1756  
Applicant: John M. Kulp  
Title: **SACRIFICIAL SURFACTANATED PRE-WET FOR DEFECT  
REDUCTION IN A SEMICONDUCTOR PHOTOLITHOGRAPHY  
DEVELOPING PROCESS**  
Attorney Docket: CT-001  
Confirmation No.: 6182

Cincinnati, OH

February 9, 2007

Mail Stop AF  
Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

Sir:

**AMENDMENT AFTER FINAL**

This paper is responsive to the final Office Action mailed October 11, 2006. The Examiner has indicated that claims 1-35 are pending in the application and are rejected. The present response includes the following:

Amendments to the Specification:	None
Amendments to the Claims:	Pages 2-9
Amendments to the Abstract:	None
Amendments to the Drawings:	None
Remarks:	Pages 10-12
Attachments:	None